Two-Dimensional Mo\textsubscript{x}W\textsubscript{1-x}S\textsubscript{2} Graded Alloys: Growth and Optical Properties

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Two-dimensional (2D) transition metal dichalcogenides can be alloyed by substitution at the metal atom site with negligible effect on lattice strain, but with significant influence on optical and electrical properties. In this work, we establish the relationship between composition and optical properties of the Mo$_x$W$_{1-x}$S$_2$ alloy by investigating the effect of continuously-varying composition on photoluminescence intensity. We developed a new process for growth of two-dimensional Mo$_x$W$_{1-x}$S$_2$ alloys that span nearly the full composition range along a single crystal, thus avoiding any sample-related heterogeneities. The graded alloy crystals were grown using a diffusion-based chemical vapor deposition (CVD) method that starts by synthesizing a WS$_2$ crystal with a graded point defect distribution, followed by Mo alloying in the second stage. We show that point defects promote the diffusion and alloying, as confirmed by Raman and photoluminescence measurements, density functional theory calculations of the reaction path, and observation that no alloying occurs in CVD-treated exfoliated crystals with low defect density. We observe a significant dependence of the optical quantum yield as a function of the alloy composition reaching the maximum intensity for the equicompositional Mo$_{0.5}$W$_{0.5}$S$_2$ alloy. Furthermore, we map the growth-induced strain distribution within the alloyed crystals to decouple composition and strain effects on optical properties: at the same composition, we observe significant decrease in quantum yield with induced strain. Our approach is generally applicable to other 2D materials as well as the optimization of other composition-dependent properties within a single crystal.
diffusion-mediated growth method. In the first step, WS₂ crystals are grown via CVD, which are then exposed to single crystals that were produced using a novel 2-step chemical vapor deposition (CVD) process based on creation of trap states, etc. As evidenced by the sharp interface between the mechanically exfoliated WS₂ (A position), that the crystal has a three-fold symmetry with pure MoS₂ in the core and gradually-shifted composition toward the exterior. This is likely due to a W-rich atmosphere during early stages of the crystal growth leading to non-stoichiometric crystal growth and formation of sulfur vacancies. This result indicates that the higher density of point defects in the core of the starting WS₂ crystal enhances Mo diffusion and results in the graded Mo concentration in the resulting alloyed structure.

To further probe the role of defects in our novel graded alloy synthesis method, we mechanically exfoliated WS₂ or MoS₂ template crystals – having a low defect density – and employed second stage CVD growth of the complementary material (Fig. 2). A WS₂ crystal was first exfoliated and deposited onto a substrate, followed by the standard MoS₂ CVD deposition. Figure 2a shows the A Raman vibrational mode for the resulting crystal and the corresponding optical microscopy and atomic force microscopy (AFM) images are provided in the Supporting Information. Figure S1. It has been demonstrated that the position of the A vibrational mode shifts linearly over the composition range from ~403 cm⁻¹ for pure MoS₂ (x = 1) to ~419 cm⁻¹ for pure WS₂ (x = 0)36. As it can be seen in Fig. 1a, the A mode in our crystals changes gradually from 400 cm⁻¹ to 415 cm⁻¹ toward the crystal edges, thus demonstrating continuously changing Mo₇₆W₁₋ₓS₂ composition. The PL peak energy map of the same crystal (Fig. 1b) corroborates the Raman results shown in Fig. 1a. The exciton emission energies of pure MoS₂ and WS₂ are 1.82 eV and 1.97 eV, respectively36, whereas the measured PL energy range spans from 1.82 eV to 1.95 eV starting from the crystal core toward edges, respectively. An additional example of a crystal demonstrating this behavior is presented in Supporting Figure S2. Taken together, these results indicate that the crystal has a three-fold symmetry with pure MoS₂ in the core and gradually-shifted composition toward the crystal edges that are composed of almost pure WS₂. This gradient in composition is quantified in Fig. 1c, calculated from the Raman data presented in Fig. 1a.

This graded spatial variation of composition seen in the final alloyed crystal structure was enabled by engineering a spatially heterogeneous concentration of point defects in the starting WS₂ crystals. Figure S3 in Supporting Information shows a Raman spectrum and the Raman intensity ratio map that compares LA(M) and A vibrational modes of a template WS₂ crystal grown using the NaCl-based CVD method. It has been previously shown that the LA(M)/A Raman intensity ratio is proportional to the inverse square of the distance between point defects with low-defect crystals having a ratio of 0.10–0.1537. WS₂ crystals grown without NaCl show a uniform ratio ≤0.151 in contrast, WS₂ crystals grown using NaCl are more defective with the ratio ranging from 1.05 at the crystal core to 0.80 at the edges. The graded LA(M)/A intensity ratio present in NaCl-assisted WS₂ crystals is indicative of a graded point defect distribution, with a greater density of defects near the crystal core compared to the exterior. This is likely due to a W-rich atmosphere during early stages of the crystal growth leading to non-stoichiometric crystal growth and formation of sulfur vacancies. This result indicates that the higher density of point defects in the core of the starting WS₂ crystal enhances Mo diffusion and results in the graded Mo concentration in the resulting alloyed structure.
interface is observed for crystals with the inverse configuration, consisting of a mechanically exfoliated MoS$_2$ core and the surrounding CVD-grown WS$_2$ (Fig. 2b).

To gain microscopic insight into the diffusion process, we performed density functional theory (DFT) modeling and explored possible diffusion-exchange mechanisms and energetics of the most likely exchange path for Mo and W atoms (Fig. 3). The DFT model consisted of a triangular single-layer WS$_2$ crystal with 45 W atoms and 103 S atoms, as shown in Figure S4 of the Supporting Information. A S vacancy, as the most probable point defect
in the crystal, was placed in the interior of the WS₂ lattice in the upper plane of chalcogen atoms. The adsorption of a single Mo impurity atom was then tested on all possible sites of the crystal. The most stable adsorption configuration consists of a Mo atom adsorbed on top of an edge W atom in the vicinity of the S vacancy, which displaces the W atom downward. This configuration is depicted as the initial stage in Fig. 3. In stage 1, the Mo atom and one coordination consists of a Mo atom adsorbed on top of an edge W atom in the vicinity of the S vacancy, which displaces neighboring S atom diffuse toward the S vacancy to temporarily form antisite defects until they eventually reach the vacancy in stage 2. At this point, the S atom fills in the original S vacancy – thereby creating a new vacancy site in the upper plane of chalcogen atoms – and the Mo atom is positioned on top of a different W atom within the crystal. In stage 3, the S atom moves from the lower plane of chalcogen atoms to the upper plane of chalcogen atoms and the Mo atom moves downward into the plane of metal atoms, forcing the W atom to occupy the S vacancy site in the lower plane of chalcogen atoms. In the final stage, the W atom is expelled further toward the crystal edge to the metal site. It is important to note that the system is capable of overcoming the stage 2 energy barrier at the experimentally tested growth temperatures. Altogether, this process demonstrates a thermodynamically viable mechanism for the inward diffusion of Mo atoms accompanied by an outward diffusion of W atoms and S vacancies, turning a relatively defective WS₂ crystal into a higher quality crystal with a Mo-rich core. This mechanism corroborates and helps to explain the S vacancy-Mo coupling in W-rich Mo₆WₓSₐ, reported by Azizi et al.39.

The unique graded structure allows us now to investigate the material properties as a function of the composition within a single crystal, thus obtained under identical synthesis conditions. Here we focus on developing understanding of the PL quantum yield as a function of the Mo/W₁₋ₓ alloy composition. Figure 4a shows normalized position-dependent PL spectra that demonstrate a continuous transition from MoS₂-like emission near the crystal core to WS₂-like emission near the crystal edges. A good fit can be obtained for each emission spectrum, providing a reliable measurement of the PL peak intensity and energy. By comparing Raman and PL peak energy maps shown in Fig. 1a,b, respectively, we can determine correlation between the local crystal composition and corresponding PL energy, shown in Figure S5 of the Supporting Information.

Furthermore, composition-dependent PL intensity gives us an important insight into the relationship between PL quantum yield and the alloy composition. Although PL quantum yield specifically refers to the ratio between electron-hole pairs generated and photons radiated, we can make reasonably accurate relative comparisons from PL intensity fluctuations within a single measurement because the laser power density and acquisition time are constant, the absorbance for monolayer MoS₂ and WS₂ at 532 nm are approximately equal, and the effects of exciton funneling are assumed to be negligible. Figure 4b maps the intensity of the PL peak determined by fitting individual PL spectra as a function of the position. By plotting the PL intensity along the lines that connect the crystal core to the triangle sides (sketched blue in Fig. 4c), it can be observed that PL intensity increases and decreases exponentially as a function of the PL energy, with the maximum PL intensity centered at ~1.87 eV (Fig. 4d).
This result suggests that the maximum PL quantum yield in Mo$_{1-x}$W$_x$$_2$ system occurs for an alloy (in our case, for $x \approx 0.5$) rather than for either of the pure extrema (MoS$_2$ or WS$_2$). In contrast to previous reports that have focused on either pure WS$_2$ and MoS$_2^{41}$ or limited-range, Mo-rich Mo$_{1-x}$Se$_x^{41}$, our results probe the PL quantum yield for nearly the entire Mo$_{1-x}$W$_x$$_2$ alloy spectrum.

Similar PL enhancement has been reported in ternary alloys of III–V semiconductors$^{43,44}$. In those material systems, the enhanced radiative recombination has been attributed to reduced carrier mobility resulting in enhanced carrier localization. However, due to the large exciton binding energy of 2D TMDs$^3$, the analogy between the two systems is not straightforward. Instead, the PL enhancement could be the result of a decrease in concentration of non-radiative point-defect related deep levels in the alloy, as theoretically predicted$^{45}$.

In addition, our results indicate that the PL quantum yield of Mo$_{1-x}$W$_x$$_2$ materials is also sensitive to strain. Figure 4d shows that the PL intensity is reduced by more than an order of magnitude for the same PL energy/crystal composition when measured from the crystal core toward the corners (sketched red in Fig. 4c). Generally, the strain accumulates at the corners due to the significant difference in temperature between growth conditions ($825^\circ$C for WS$_2$ and $680^\circ$C for MoS$_2$) and room temperature as well as the difference in the coefficient of thermal expansion between TMDs and the substrate, SiO$_2$. In our crystals, this strain is evidenced in AFM height and phase maps (Supporting Figure S6). Given the low PL intensity in the strained regions at all compositions, we can conclude that the strain-dependent effects on PL quantum yield supersede the composition-dependent effects. Therefore, it is evident that strain must be well-controlled, whether through crystal transfer$^{46}$, substrate choice$^{47}$ or other means, to control the luminescence yield regardless of crystal composition.

In conclusion, we have established the relationship between PL intensity and alloy composition ($x$) within single crystals of Mo$_{1-x}$W$_x$$_2$ graded alloys that span nearly the entire composition range. Our results show an exponential increase of the quantum yield with increased alloying, reaching the maximum value for equicompositional alloy Mo$_{0.5}$W$_{0.5}$S$_2$ ($x=0.5$), which is two orders of magnitude enhanced compared to the values for pure MoS$_2$ ($x=1$) and pure WS$_2$ ($x=0$). Such observation is consistent with theoretical prediction that alloying could suppress the deep in-gap level responsible for non-radiative recombination, and offers the venue for improving optical performance of TMD materials. Additionally, we demonstrated that the introduction of the strain leads to suppression of PL intensity for all the compositions of the alloy. The synthesis of graded alloys was achieved by diffusion-driven metal exchange in the pure TMD template crystals. Our DFT calculations reveal a thermodynamically favorable diffusion-exchange reaction path for controlled alloying, controlled by the sulfur vacancies. Our approach can be extended to other TMDs and future experiments to engineer the defect distribution by other means (e.g. laser, O$_2$ plasma, annealing in air etc.) that would enable a higher degree of control over compositional tuning and patterning in a crystal. On-demand alloys such as these could be useful in several applications that require controlled, directional anisotropy of optical and/or electrical properties.

Methods

Sample Preparation. Mo$_{1-x}$W$_x$$_2$ alloys were grown in two subsequent CVD steps at ambient pressure using Ar as a carrier gas. A bare Si wafer substrate with a 300-nm thick SiO$_2$ layer was suspended above an alumina boat containing the metal precursor powder at the center of the CVD furnace. Sulfur powder (Sigma-Aldrich, 99.5%), the chalcogen precursor, was placed in another alumina boat and was initially outside of the furnace, at the upstream end of the 1-inch quartz tube. Once the furnace reached the growth temperature, the sulfur was introduced to the upstream of the furnace using magnets to reach approximately $200^\circ$C. In the first growth step, WS$_2$ crystals were grown at $825^\circ$C for 30 min using tungsten trioxide (WO$_3$, Sigma-Aldrich, 99.9%) mixed with sodium chloride (NaCl) in a 9:2 mass ratio as the metal precursor with an Ar flow rate of 50 sccm. In the second growth step, the metal precursor was replaced with molybdenum trioxide (MoO$_3$, Sigma-Aldrich, 99.9%), the growth temperature was reduced to 680°C and Ar flow rate to 25 sccm. Exfoliated crystals were produced from bulk samples by mechanical exfoliation.

Sample Characterization. Optical images were recorded using a Leica DFC 450 C microscope. AFM images were recorded with a Bruker Dimension Fastscan AFM using a tapping mode. Raman and PL measurements were performed on WITec Alpha 300 R and Horiba Jobin Yvon LabRAM HR800 confocal Raman microscopes under ambient conditions at room temperature. A 532 nm laser was focused onto the sample using a 100× objective resulting in a spot size of ~1 μm in diameter. 1800 and 600 lines/mm grating were used in Raman and PL measurements, respectively.

DFT Calculations. Computational results utilize density functional theory implemented in Vienna ab-initio Simulation Package$^{51,52}$. The plane-wave basis with the cut-off energy of 400 eV and the generalized gradient approximation in the Perdew-Burke-Ernzerhof (PBE) format$^{53}$ with the projector-augmented wave method$^{54}$ were employed in all calculations. The structural relaxations were carried out until the Hellmann-Feynman force on each atom is less than 0.01 eV/Å, and the energy convergence criterion was set to 10$^{-5}$ eV. Gamma-point-only $k$ sampling is adopted for calculations.

References


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Author Contributions
K.B., S.L. and T.L. performed the experiments. N.G. and C.Z. performed the density functional theory calculations. K.B. analyzed the data. K.B., S.G. and S.G. wrote the manuscript. All authors have read and discussed the manuscript.

Additional Information
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